

Remarks Regarding the Amendments

In the course of preparing a response to this restriction requirement, Applicants detected a typographic error that was carried throughout the application. Namely, rather than recite that component (c) comprises an alkyl group as was correctly stated numerous times (see e.g. page 4, lines 14-15, page 12, lines 19-23, and claim 25), the amended paragraph in the specification and claims 20 and 27 contained a typographic error of “alkenyl” rather than “alkyl”. The present amendments now consistently require the presence of an alkyl group on component (c).

Response to the Restriction Requirement

The Office issued the following restriction requirement:

Group I – claims 1-21, 30-31 “drawn to a method of making a resin (sic)”.

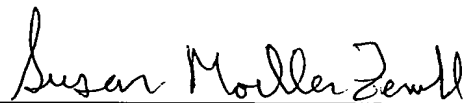
Group II – claims 22-23, 29 “drawn to an integrated circuit article”

Group III – claims 24-28 drawn to a composition.

Applicants hereby elect with traverse group III, claims 24-28, addressed to a composition. Applicants specifically object to the restriction because claims 29-31 are addressed to methods of making and using the composition of the elected group. See also claims 18-21 and 23 which are uses of the composition claimed in the elected group. Therefore, if the composition is patentable, these claims would also be patentable and it would not be burdensome to the examiner to examine these claims together.

Applicants further note that claims 1-21 are addressed to a method useful in making a microelectronic device rather than a method of making a resin as stated in the restriction requirement.

Respectfully submitted,



Susan Moeller Zerull  
Registration No. 38,367  
Phone: 989.636.8858

P. O. Box 1967  
Midland, MI 48641-1967

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